

Search Notes**Application/Control No.**

10/777,680

Applicant(s)/Patent under Reexamination

ETO ET AL.

Examiner

JASON L. LAZORCIK

Art Unit

1791

SEARCHED

Class	Subclass	Date	Examiner
065	30.13, 30.14	9/25/2006	JLL

INTERFERENCE SEARCHED

Class	Subclass	Date	Examiner

**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
Inventor Search: Nobuyuki Eto Hideki Isono	9/25/2006	JLL
Class Search (Key word limited)	9/25/2006	JLL
EAST Search (See Search History)	9/25/2006	JLL
Update EAST Search	4/16/2007	JLL
Updated EAST Search Substrate thickness 0.2-0.9mm	10/29/2007	JLL
Updated Search NPL searched for residual stress profile in chemically tempered glass. Note: engineered stress profile (ESP)	8/17/2008	JLL
Updated EAST Search Lithium Glass magnetic disk substrate	4/8/2009	JLL
Updated Search	11/10/2009	JLL